



Photonics21 President Candidate 2016 – 18

**Aldo Kamper, CEO
OSRAM Opto Semiconductors**

Members Photonics21 Executive Board Nomination Committee

- Giorgio Anania
- Bernd Schulte
- Roberta Rampon
- Mike Wale
- Thomas Rettich

Aldo Kamper – Chief Executive Officer of OSRAM Opto Semiconductors GmbH
(since October 2010)



Personal Information

Date of Birth: June 4, 1970
Place of Birth: Leischendam, Netherlands

Professional Experience

1994 - 1997	OSRAM GmbH Munich, Germany	Controller Affiliated Companies
1999 - 2001	OSRAM Opto Semiconductors GmbH Regensburg, Germany	Director Visible LED Automotive
2001 - 2006	OSRAM Opto Semiconductors GmbH Regensburg, Germany	Vice President and General Manager LED
2006 - 2009	OSRAM Sylvania Hillsboro, NH, USA	Executive Vice President and General Manager Automotive Lighting NAFTA
2009 – Oct 2010	OSRAM Sylvania Hillsboro, NH, USA	Executive Vice President and General Manager Speciality Lighting NAFTA
Since Oct 2010	OSRAM Opto Semiconductors GmbH Regensburg, Germany	President & CEO

Education

1988 - 1994	University of Limburg	Master in Business
1997 - 1999	Stanford Graduate School of Business	M.B.A.

OSRAM Opto Semiconductors GmbH is the world's second largest manufacturer of optoelectronic semiconductors for the illumination, sensing and visualisation sectors. It combines extensive know-how in semiconductor technology, opto-electronic and converter materials and packages under one roof. The extensive semiconductor product portfolio includes high-power LEDs in the visible range, high-performance infrared LEDs, high-quality optoelectronic detectors and sensors, and high-power semiconductor lasers. In Regensburg, Germany the most advanced optical chip factory in the world was opened in April 2003, was expanded in 2007, and employs around 2300 people. A core competence of the OSRAM Opto Semiconductors GmbH technology team is the continuous transfer of research and development results into mass production. The OSRAM Opto Semiconductors GmbH team is equipped with all facilities to develop high-tech optoelectronic devices. The entire production chain of opto devices from III-V epitaxial growth through photolithography, metal and TCO material deposition, passivation using various methods, e.g. CVD, sputtering, ALD, plasma etching, chip singulation, optical and electrical chip characterization up to device packaging including phosphor technology is available. Lifetime test and qualification equipment is used to assist the research activities. The company benefits from more than thirty years of experience in the development and production of optoelectronic semiconductor components. This is evidenced by more than 6,500 patents in the various areas of photonic and semiconductor technology.